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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/754,597	01/12/2004	Yoshifumi Takeyama	03560.003426	8030
5514 FITZPATRICI	7590 08/06/2007 K CELLA HARPER & SC	EXAMINER		
30 ROCKEFELLER PLAZA			HALL, ASHA J	
NEW YORK, NY 10112			ART UNIT	PAPER NUMBER
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Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)				
	10/754,597	TAKEYAMA ET AL.				
Office Action Summary	Examiner	Art Unit				
	Asha Hall	1753				
The MAILING DATE of this communication	n appears on the cover sheet w	vith the correspondence address				
Period for Reply						
A SHORTENED STATUTORY PERIOD FOR RI WHICHEVER IS LONGER, FROM THE MAILIN - Extensions of time may be available under the provisions of 37 CF after SIX (6) MONTHS from the mailing date of this communicatio - If NO period for reply is specified above, the maximum statutory p - Failure to reply within the set or extended period for reply will, by s Any reply received by the Office later than three months after the rearned patent term adjustment. See 37 CFR 1.704(b).	G DATE OF THIS COMMUNI FR 1.136(a). In no event, however, may a n. eriod will apply and will expire SIX (6) MOI statute, cause the application to become Al	CATION. reply be timely filed NTHS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).				
Status	•					
1) Responsive to communication(s) filed on	January 12, 2004.					
, <u> </u>	,					
	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice und	der <i>Ex parte Quayle</i> , 1935 C.L	D. 11, 453 O.G. 213.				
Disposition of Claims						
4) Claim(s) 1-13 is/are pending in the application	○☑ Claim(s) <u>1-13</u> is/are pending in the application.					
4a) Of the above claim(s) is/are with	ndrawn from consideration.					
5) Claim(s) is/are allowed.						
6) Claim(s) 1-13 is/are rejected.						
7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction a	nd/or election requirement					
or ordinates are subject to restriction a	nazor election requirement.					
Application Papers	•					
9) The specification is objected to by the Exam						
10)☐ The drawing(s) filed on is/are: a)☐	•	•				
Applicant may not request that any objection to						
Replacement drawing sheet(s) including the control of the oath or declaration is objected to by the	· ·					
Priority under 35 U.S.C. § 119	,					
12)⊠ Acknowledgment is made of a claim for for a)⊠ All b)□ Some * c)□ None of:	eign priority under 35 U.S.C.	§ 119(a)-(d) or (f).				
1.⊠ Certified copies of the priority docur	nents have been received.					
2. Certified copies of the priority docur		··· . ——				
3. Copies of the certified copies of the	·	received in this National Stage				
application from the International Bu * See the attached detailed Office action for a		treceived				
	a not of the certified copies flot	CTOOOTYGU.				
Attachment(s) 1) Notice of References Cited (PTO-892)	4) 🗖 Intanciau	Summary (PTO-413)				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948	Paper No	(s)/Mail Date				
3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date <u>May 5, 2004</u> .	5) Notice of 6) Other:	Informal Patent Application				

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1,3, and 5-13 are rejected under 35 U.S.C. 102(b) as being anticipated by Shiotsuka et al. (6,175,075).

In regard to claim 1, Shiotsuka et al. discloses photovoltaic cell comprising:

- a photovoltaic element (col.1; lines:14-22);
- a coating film (406b) provided on the photovoltaic element as shown in
 Figure 4, wherein the photovoltaic element has an electrode
 portion/collecting electrode metallic wire (406a) having a thickness larger
 than the average thickness of the coating film (col.14: lines: 57-68 &
 col.15; lines: 1-9)
- a thickness of a part of the coating film (406b), which is in contact with the electrode portion/collecting electrode metallic wire (406a) is equal to the average thickness of the coating film (col.14: lines: 57-68 & col.15; lines: 1-9).

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With respect to claim 3, Shiotsuka et al. discloses photovoltaic cell as applied to claim 1, wherein the average thickness of the coating film is 0.001-0.05mm (col.14: lines: 57-68 & col.15; lines: 1-9).

In regard to claims 5 and 6, Shiotsuka et al. discloses the photovoltaic cell according to claim 1, wherein the coating film comprises a coating material (406b), and the electrode portion comprises an insulating member (405) and a conductive/metal foil body (408) (col. 10; lines: 11-14 & col. 13; lines: 5-6). Shiotsuka et al. also discloses wherein the insulating member (405) comprises an acrylic resin adhesive layer (col.14; lines: 29-33).

With respect to claim 7, Shiotsuka et al. discloses the photovoltaic cell as applied to claim 5 above, wherein a part of the insulating member (405) as shown in Figure 4 located at a position higher (on the sides; surrounding electrode portion (406)) than the average thickness of the coating film has a low wettability of 45 dyne/cm (col.18; lines: 59-61) to the coating material (406b).

With respect to claims 8 and 9, Shiotsuka et al. discloses the photovoltaic cell as applied to claim 7 above, wherein a side surface (Figure 4) of the insulating member (405) comprises an agent/organic peroxide (col.5; lines: 29-31) causing the side surface of the insulating member to have a low wettability of 45 dyne/cm (col.18; lines: 59-61) to the coating material (406b), the side surface of the insulating member (405) being located at a side of the electrode portion (406) which is in contact with the coating film as shown in Figure 4. Shiotsuka also discloses wherein the insulator includes base plate/reinforcement member is comprised of a crosslinking agent of organic peroxide

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(col.7; lines: 21-22 & col. 19; lines: 23-34).

With respect to claim 10, Shiotsuka et al. discloses method for manufacturing a photovoltaic cell having a photovoltaic element and a coating film provided on the photovoltaic element (col.2; lines: 60-67), comprising:

- a step of forming the coating film on a light receiving face of the photovoltaic
 element by applying the coating film thereon (col.11; lines: 36-44); and
- a step of heating the coating film for curing/thermocompression bonding treatment (col.19; lines: 61-62) while a part thereof in contact with an electrode portion (406) as shown in Figure 4, of the photovoltaic element is being maintained such that it has a thickness equal to or smaller than the average thickness of the coating film (col.14: lines: 57-68 & col.15; lines: 1-9).

In regard to claim 11, Shiotsuka et al. discloses a method for manufacturing a photovoltaic cell (col.2; lines: 60-67) as applied to claim 10, further comprising a step of coating a side surface of an insulating member (405) of the electrode portion (406) with an agent/organic peroxide (col.5; lines: 29-31) which causes the side surface of the insulating member to have a low wettability of 45 dyne/cm (col.18; lines: 59-61) to a coating material/resin contained in the coating film (406b) as shown in Figure 4, wherein the side surface of the insulating member(405) is located at a side of the electrode portion(406) which is brought into contact with the coating film(406b).

With respect to claim 12, Shiotsuka et al. discloses a method for manufacturing a

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photovoltaic cell as applied to claim 11 above, wherein the agent is a release agent contained in a mixed solution at a concentration of 0.1 to 30 % (col.17; lines: 44-50).

In regard to claim 13, Shiotsuka et al. discloses a method for manufacturing a photovoltaic cell as applied to Claim 10 above,

- further comprising a step of forming an insulating member (405) of the electrode portion (406) by slitting a tape comprising a base plate (409) (col.15; lines: 32-36),
- wherein the base plate (409) and a side surface of the insulating member comprise an agent is comprised of a crosslinking agent of organic peroxide (col.7; lines: 21-22 & col. 19; lines: 23-34) which causes the side surface of the insulating member to have a low wettability ~ 45 dyne/cm (col.18;lines:59-61) to a coating material contained in the coating film (406b), and
- wherein the side surface of the insulating member(405) is located at a side of the electrode portion(406), which is brought into contact with the coating film(406b).

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

4. Claims 2 and 4 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shiotsuka et al. (6,175,075) in view of Nakamura (6,291,763).

With respect to claim 2, Shiotsuka et al. discloses photovoltaic cell (col.1; lines: 14-22) as applied to claim 1 above, disclose that the coating film comprises a thermosetting coating material (406b)/resin(col. 14; lines: 65-67) (wherein thermosets is a distinct property of resins), but fails to discloses the thermosetting coating material before curing has a viscosity in the range of from 1 to 50 mPa*s.

Nakamura discloses a photoelectric conversion device and photocell (col. 1; lines: 5-8) and further discloses coating material with a viscosity of 1 mPa*s (col. 7; lines; 6-8). Nakamura teaches that the liquid viscosity is largely dependent on the kind and dispersibility of the semiconductor particles, the solvent, additives, and a binder in order to form a uniform film extrusion coating or casting (col. 7; lines: 4-9). It would have been obvious to one of ordinary skill in the art at the time of the invention to incorporate a liquid viscosity of 1 mPa*s for the coating material as taught by Nakamura to the photovoltaic cell of Shiotsuka et al. in order to form a uniform film coating.

In regard to claim 4, Shiotsuka et al. discloses the photovoltaic cell as applied to claim 1, and further discloses a coating film (406b), but fails to disclose wherein the coating film comprises an acrylic resin.

Nakamura discloses a photoelectric conversion device and photocell (col. 1; lines: 5-8) and further discloses coating/sealing material composed of an acrylic resin in accordance with the purposes such as improvement on weatherability, electrical insulation, improvement on light collection efficiency, protection of cells and the like (col.

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31; lines: 22-29). It would have been obvious to one of ordinary skill in the art at the time of the invention to incorporate an acrylic resin as the coating material as taught by Nakamura to the photovoltaic cell of Shiotsuka et al. in order to improve upon the electrical properties, light collection efficiency and the protection of the cells.

Conclusion

5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Asha Hall whose telephone number is 571-272-9812. The examiner can normally be reached on Monday-Thursday 8:30-7:00PM EST.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Alexa Neckel can be reached on 571-272-1446. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

ALEXA D. NECKEL
SUPERVISORY PATENT EXAMINER

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